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APPLICATION NO.	FIL	ING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/648,172	8,172 08/25/2003		· Sung-Kwon Lee	51876P377	4454
8791	7590	05/05/2005		EXAM	INER
BLAKELY 12400 WILS		FF TAYLOR &	CHEN, KI	N CHAN	
SEVENTH F		ALL VARD		ART UNIT	PAPER NUMBER
LOS ANGEI	LES, CA	90025-1030		1765	

DATE MAILED: 05/05/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

			( W.				
	Application No.	Applicant(s)					
	10/648,172	LEE, SUNG-KWON	1				
Office Action Summary	Examiner	Art Unit					
	Kin-Chan Chen	1765					
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet w	vith the correspondence add	iress				
A SHORTENED STATUTORY PERIOD FOR REPL' THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a repl' - If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a y within the statutory minimum of the will apply and will expire SIX (6) MCs, cause the application to become the second	reply be timely filed irty (30) days will be considered timely NTHS from the mailing date of this contains the mailing date of this contains and the mailing date.	mmunication.				
Status							
1) Responsive to communication(s) filed on	<u>_</u> .						
·—	action is non-final.	•					
• •	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims			· .				
4) ⊠ Claim(s) 1-19 is/are pending in the application 4a) Of the above claim(s) is/are withdray 5) □ Claim(s) is/are allowed. 6) □ Claim(s) is/are rejected. 7) □ Claim(s) is/are objected to. 8) ⊠ Claim(s) 1-19 are subject to restriction and/or	wn from consideration.	<i>,</i>					
Application Papers			•				
9)☐ The specification is objected to by the Examine							
10) The drawing(s) filed on is/are: a) acc							
Applicant may not request that any objection to the			D 4 404/4\				
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex							
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	ts have been received. ts have been received in nity documents have bee u (PCT Rule 17.2(a)).	Application No n received in this National	Stage				
Attachment(s)							
1) Notice of References Cited (PTO-892)		y Summary (PTO-413) o(s)/Mail Date					
Notice of Draftsperson's Patent Drawing Review (PTO-948)     Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)     Paper No(s)/Mail Date		Informal Patent Application (PTC	-152)				

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## **DETAILED ACTION**

## Election/Restrictions

1. This application contains claims directed to the following patentably distinct species of the claimed invention:

I. fabricating device using three hardmasks method for etching conducting layer including forming a first hardmask pattern by etching the third hardmask; forming a second hard mask pattern by etching the second hardmask using the first hardmask pattern as a mask (e.g., claims 1-12).

II. fabricating device using two hardmasks method for etching conducting layer including forming a first hardmask pattern by etching the second hardmask pattern (e.g., claims 13-19).

2. Applicant is required under 35 U.S.C. 121 to elect a single disclosed species for prosecution on the merits to which the claims shall be restricted if no generic claim is finally held to be allowable. Currently, no claim is generic.

Applicant is advised that a reply to this requirement must include an identification of the species that is elected consonant with this requirement, and a listing of all claims readable thereon, including any claims subsequently added. An argument that a claim is allowable or that all claims are generic is considered nonresponsive unless accompanied by an election.

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Upon the allowance of a generic claim, applicant will be entitled to consideration of claims to additional species which are written in dependent form or otherwise include all the limitations of an allowed generic claim as provided by 37 CFR 1.141. If claims are added after the election, applicant must indicate which are readable upon the elected species. MPEP § 809.02(a).

Should applicant traverse on the ground that the species are not patentably distinct, applicant should submit evidence or identify such evidence now of record showing the species to be obvious variants or clearly admit on the record that this is the case. In either instance, if the examiner finds one of the inventions unpatentable over the prior art, the evidence or admission may be used in a rejection under 35 U.S.C. 103(a) of the other invention.

Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kin-Chan Chen whose telephone number is (571) 272-1461. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published

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applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business

Center (EBC) at 866-217-9197 (toll-free).

May 2, 2505

Kin-Chan Chen Primary Examiner Art Unit 1765

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